

APPLICATION DATA SHEET

APPLICATION INFORMATION

Application Type:: REGULAR
Subject Matter:: UTILITY
CD-ROM or CD-R?:: NONE
Title:: SEMICONDUCTOR DEVICE HAVING
METAL SILICIDE FILMS FORMED ON
SOURCE AND DRAIN REGIONS AND
METHOD FOR MANUFACTURING THE
SAME
Attorney Docket Number:: 247866US2S
Total Drawing Sheets:: 5
Small Entity?:: NO

INVENTOR INFORMATION

Applicant Authority Type:: INVENTOR
Primary Citizenship Country:: Japan
Status:: FULL CAPACITY
Given Name:: Akira
Family Name:: HOKAZONO
City of Residence:: Sagamihara-shi
Country of Residence:: Japan
Street of Mailing Address:: c/o Intellectual Property Division,
Toshiba Corporation,
1-1, Shibaura 1-chome, Minato-ku
City of Mailing Address:: Tokyo
Country of Mailing Address:: Japan
Postal or Zip Code of Mailing Address:: 105-8001

Applicant Authority Type:: INVENTOR
Primary Citizenship Country:: Japan
Status:: FULL CAPACITY
Given Name:: Kazuya
Family Name:: OHUCHI
City of Residence:: Yokohama-shi
Country of Residence:: Japan
Street of Mailing Address:: c/o Intellectual Property Division,
Toshiba Corporation,
1-1, Shibaura 1-chome, Minato-ku
City of Mailing Address:: Tokyo
Country of Mailing Address:: Japan
Postal or Zip Code of Mailing Address:: 105-8001

CORRESPONDENCE INFORMATION

Correspondence Customer Number:: 22850

REPRESENTATIVE INFORMATION

Representative Customer Number:: 22850

FOREIGN PRIORITY INFORMATION

Application Number:	Country::	Filing Date::	Priority Claimed::
2003-077648	Japan	03/20/03	YES